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## Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims in the application:

## Listing of Claims:

1. (Currently Amended) A retaining ring comprising:

a generally annular body having a top surface, a bottom surface, an inner diameter surface, and an outer diameter surface, wherein the bottom surface includes a plurality of channels, each channel extending from the inner diameter surface to the outer diameter surface and having a <u>curved section defining a rounded ceiling</u> and substantially vertical side-walls, wherein a distance between the side-walls is constant from the bottom surface to the curved section and the side-walls have a length that is greater than the depth of the curved section.

- (Original) The retaining ring of claim 1, wherein the rounded ceiling has a semicircular cross-section.
- (Original) The retaining ring of claim 2, wherein the semi-circular cross-section has a diameter about equal to a width of the channel.
- (Original) The retaining ring of claim 1, wherein the rounded ceiling has a flat portion.
- (Previously Presented) The retaining ring of claim 4, wherein the rounded ceiling is rounded at an intersection of the flat portion and the vertical side-walls of the channel.
  - 6. (Cancelled)

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 (Original) The retaining ring of claim 1, wherein the plurality of channels have substantially uniform depth.

- (Original) The retaining ring of claim 1, wherein the plurality of channels are
  oriented at an angle relative to a radial segment extending through the center of the retaining
  ring.
- 9. (Original) The retaining ring of claim 8, wherein the angle is between  $30^\circ$  and  $60^\circ$ .
- (Original) The retaining ring of claim 1, wherein the outer diameter surface includes a ledge.
- (Original) The retaining ring of claim 10, wherein the outer diameter surface
  includes a first portion adjacent the bottom surface that has an outer diameter less than a second
  portion adjacent the top surface.
- (Previously Presented) The retaining ring of claim 10, wherein the vertical sidewalls extend to substantially the same depth as the ledge.
- (Original) The retaining ring of claim 1, wherein the annular body comprises a wearable material.
- 14. (Original) The retaining ring of claim 1, wherein the annular body comprises an upper portion and a lower portion, the upper portion being more rigid than the lower portion.
- (Original) The retaining ring of claim 14, wherein the channels are formed in the lower portion.

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 (Original) The retaining ring of claim 15, wherein the lower portion is formed of a wearable material.

- 17. (Original) The retaining ring of claim 15, further comprising a plurality of passages extending through the upper portion from the inner diameter surface to the outer diameter surface.
- (Previously Presented) The retaining ring of claim 1, wherein the plurality of channels are distributed at substantially equal angular intervals around the retaining ring.
  - 19. (Currently Amended) A carrier head comprising:
  - a substrate receiving surface;
- a generally annular retaining ring surrounding the substrate receiving surface, the retaining ring having a top surface, a bottom surface, an inner diameter surface, and an outer diameter surface, wherein the bottom surface includes a plurality of channels, each channel extending from the inner diameter surface to the outer diameter surface and having a <u>curved section defining a</u> rounded ceiling and substantially vertical side-walls, <u>wherein a distance between the side-walls is constant from the bottom surface to the curved section and the side-walls have a length that is greater than the depth of the curved section.</u>
  - (Currently Amended) A method of polishing, comprising:
     creating relative motion between a substrate and a polishing surface; and

restraining the substrate with retaining ring that has a top surface, a bottom surface, an inner diameter surface, and an outer diameter surface, wherein the bottom surface includes a plurality of channels, each channel extending from the inner diameter surface to the outer diameter surface and having a curved section defining a rounded ceiling and substantially vertical side-walls, wherein a distance between the side-walls is constant from the bottom surface to the curved section and the side-walls have a length that is greater than the depth of the curved section; and

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supplying a polishing liquid to the polishing surface so that the polishing liquid flows through the channels and beneath the retaining ring to the substrate.

21. (New) The retaining ring of claim 1, wherein the side-walls of each channel are parallel to one another for a depth of at least 0.030 inches.